



# Ultra-broadband polarization beam splitter with a gradual anisotropy engineered subwavelength metamaterial

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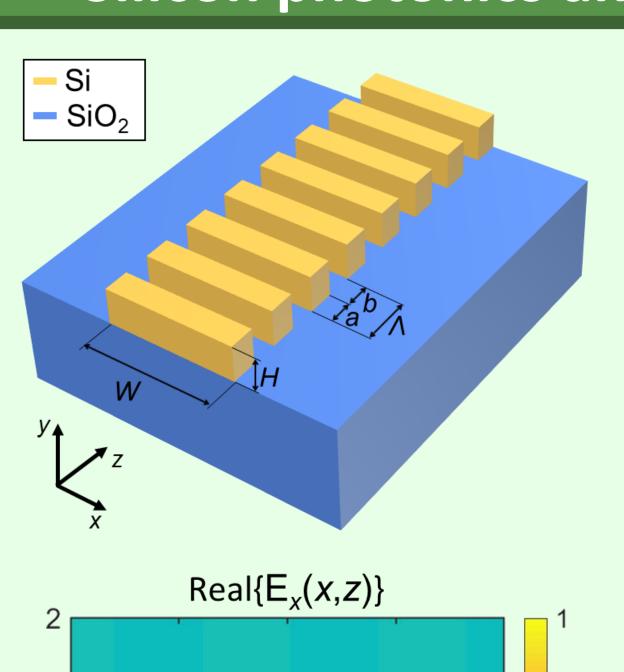
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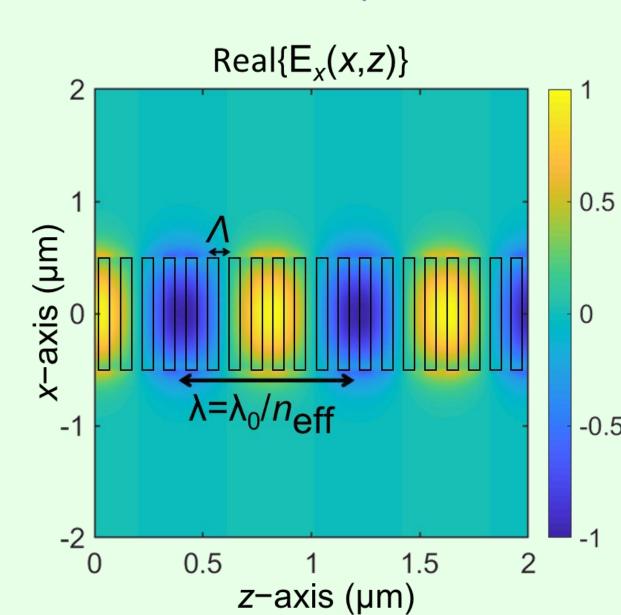
In this work we propose a polarization beam splitter based on an advanced SWG metamaterial topology which controls the propagation of multiple TE and TM modes at the same time. The proposed device achieves a simulated insertion loss <1 dB and extinction ratio >20 dB over a 400 nm bandwidth.

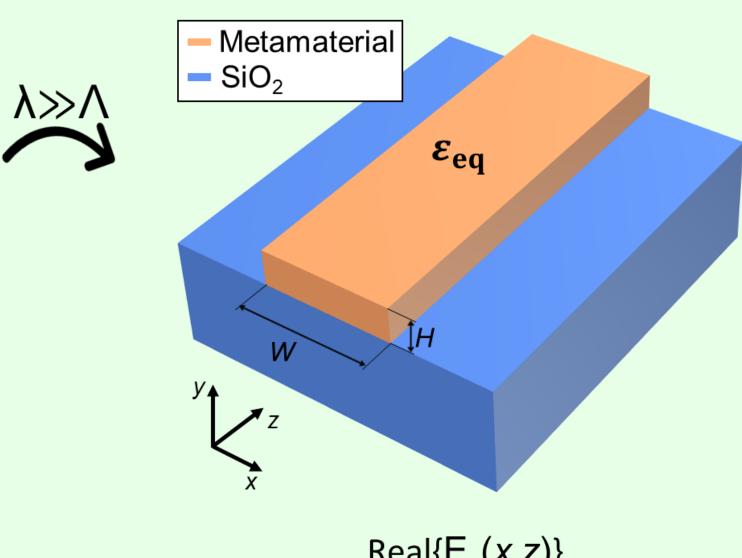
#### Silicon photonics is leading the landscape of with Silicon-Onphotonics, integrated Insulator (SOI) platform having important commercial applications specially on the data/telecom industry [1].

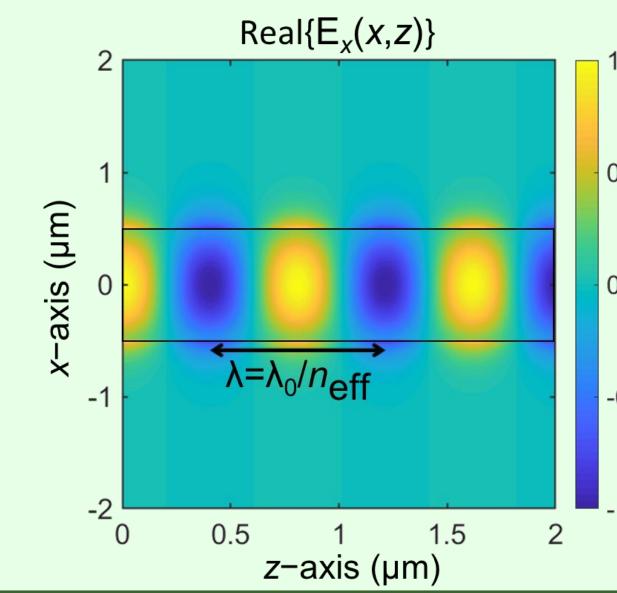
- The huge success of SOI principally comes from its high integration density and the compatibility of the fabrication process of SOI chips with the CMOS process
- However, CMOS compatibility comes with the drawback of restricting the available materials to those compatible with the fabrication process, hindering the design of highperformance devices.
- Subwavelength grating (SWG) metamaterials circumvent the restriction on the available materials by behaving as homogeneous anisotropic material with tailorable optical properties [2].

# Silicon photonics and SWG metamaterials









The condition for a periodic structure to work as a homogeneous metamaterial is:

$$\Lambda < \lambda_0 / 2n_{eff}$$

homogeneous metamaterial equivalent to an SWG structure is characterized by its permittivity tensor:

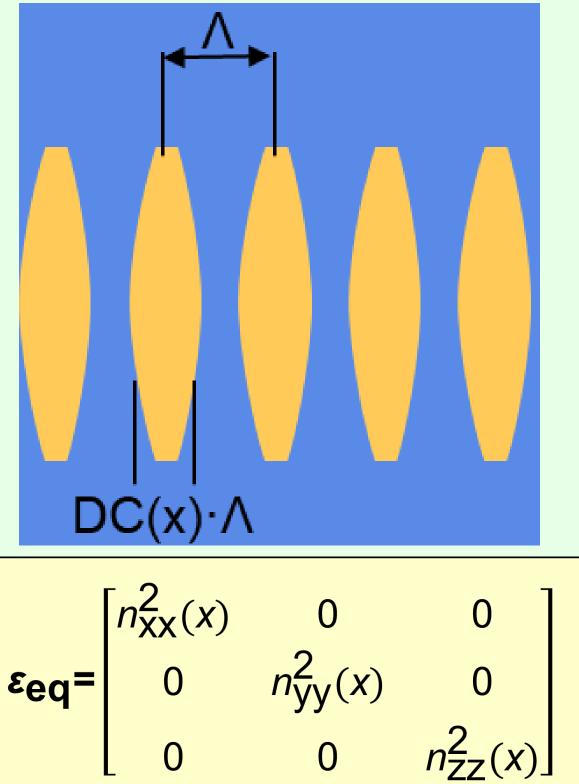
$$\boldsymbol{\varepsilon_{eq}} = \begin{bmatrix} n_{XX}^2 & 0 & 0 \\ 0 & n_{YY}^2 & 0 \\ 0 & 0 & n_{ZZ}^2 \end{bmatrix}$$

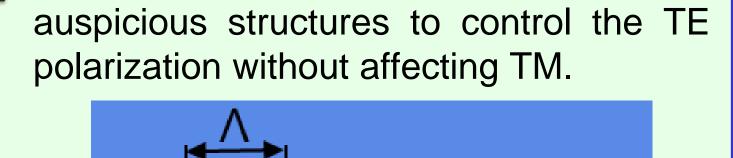
These tensor components can be calculated in a first approach as:

$$n_{XX}^2 = n_{yy}^2 = DC \cdot n_{Si}^2 + (1 - DC) \cdot n_{SiO_2}^2$$
  
 $n_{ZZ}^{-2} = DC/n_{Si}^2 + (1 - DC)/n_{SiO_2}^2$ 

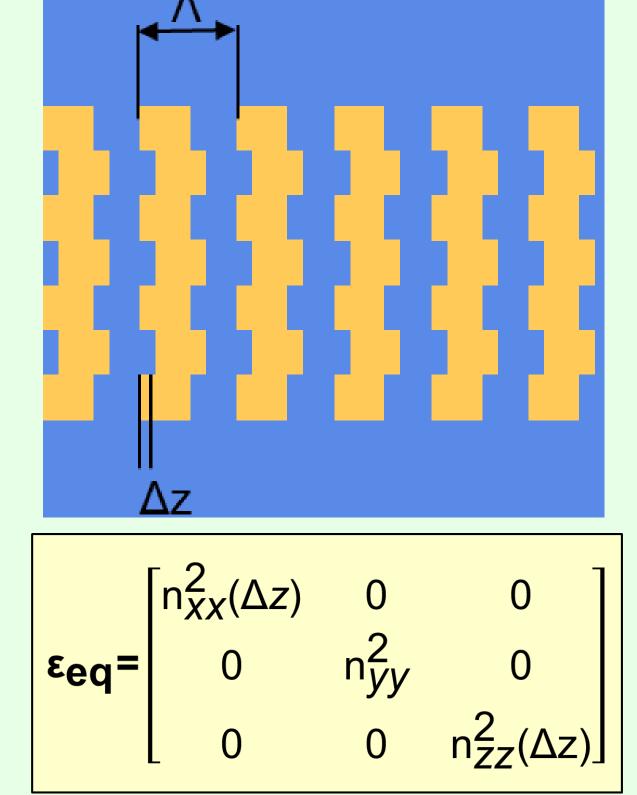
### Advanced SWG metamaterials topologies

Gradual subwavelength gratings [3] offer virtually complete control over light propagation in photonic chips.



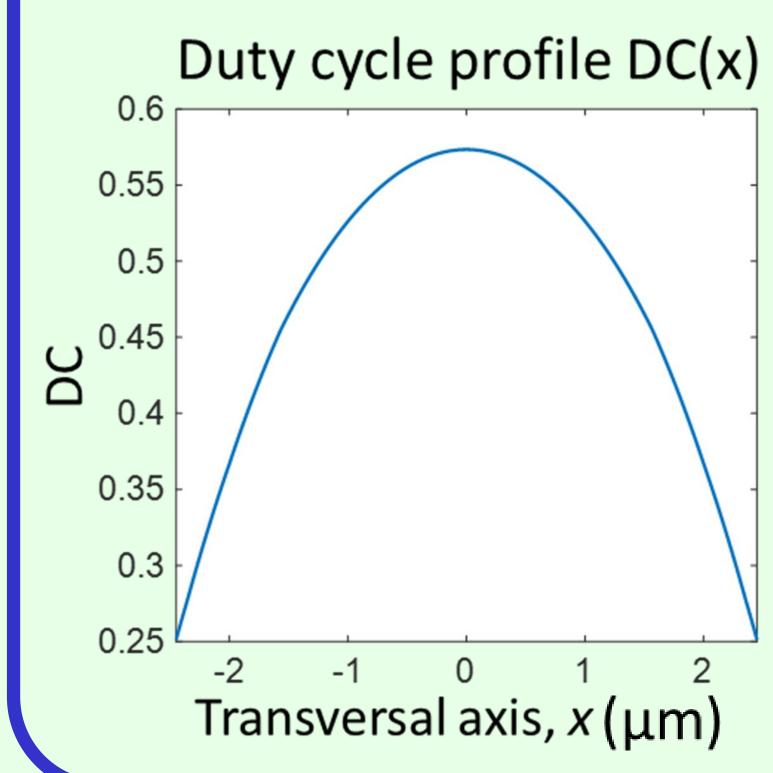


Bricked subwavelength gratings [4] are



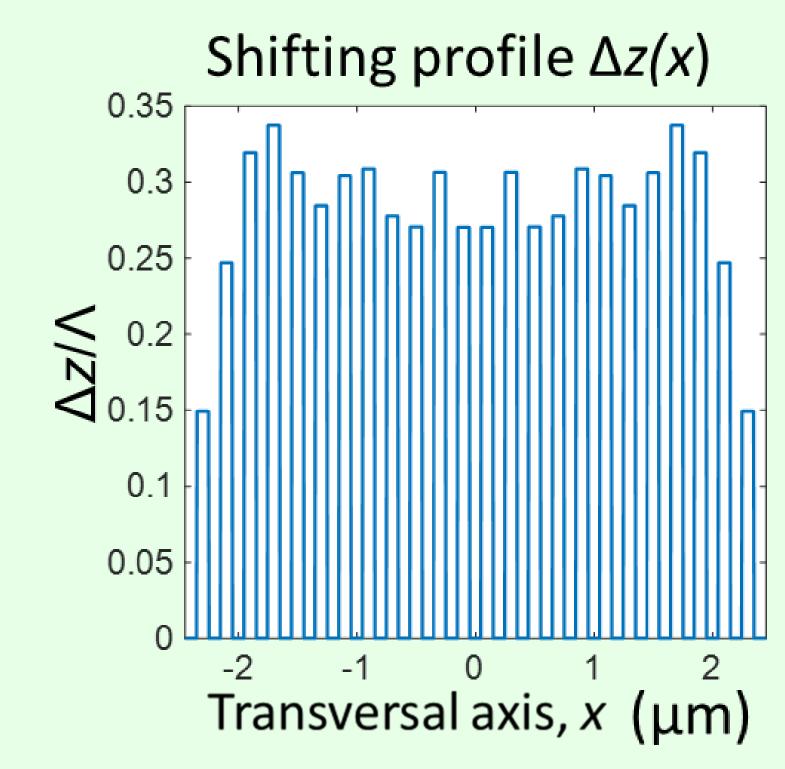
### Design of a GRIN bricked lens

The gradualness profile on the duty cycle, DC(x), enables the implementation of a GRIN lens working for both polarizations with focus lengths,  $f_{TE}$  and  $f_{TM}$ .

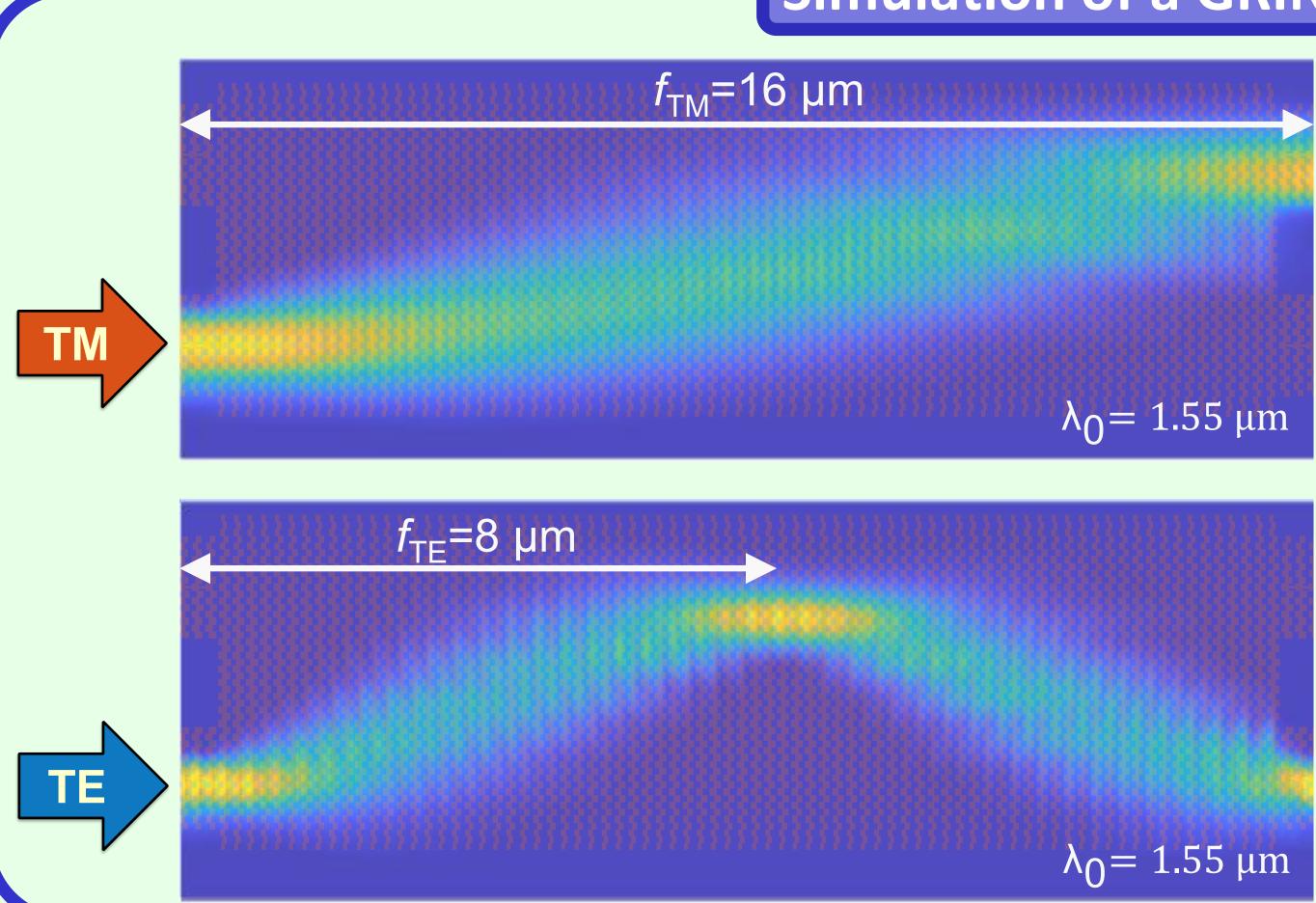


The shifting profile of the bricked topology,  $\Delta z(x)$ , enables the tuning of the TE focal length, enabling to satisfy the polarization splitting condition:  $2f_{TE} = f_{TM}$ 

1.6

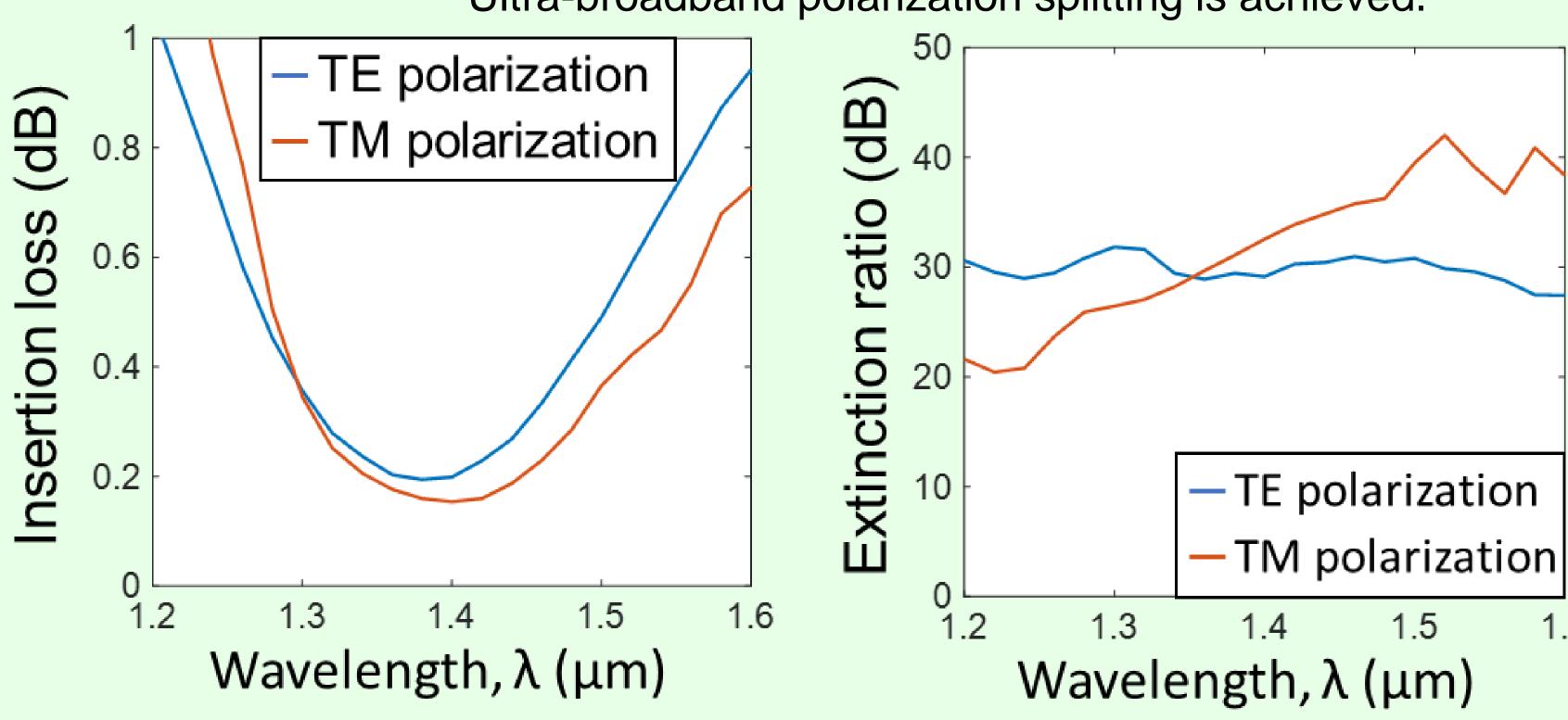


# Simulation of a GRIN bricked lens polarization beam splitter



The focus length of GRIN lenses is wavelength independent!!!

Ultra-broadband polarization splitting is achieved.



#### References

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- [2] J. M. Luque-González, A. Sánchez-Postigo, et al, "A review of silicon subwavelength gratings: building break-through devices with anisotropic metamaterials," Nanophotonics, 10, 11, (2021)
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